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Dimensionality-induced insulator-metal crossover in layered nickelates $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ ($n = 2, 3, \text{ and } \infty$)

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Low-valence layered nickelates are a structural analog to the superconducting cuprates and possess interesting properties. In this work, we have systematically studied the electronic structure of $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ using first-principles calculations. Our results reveal that the Ni-3d $3z^2 - r^2$ orbital state is active and evolves from discrete molecular levels to a continuous solid band and its filling varies as the dimensionality (or n) increases. The two-dimensional (2D) $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$ are thus found to have a molecular insulating state. In contrast, the 3D LaNiO_2 is metallic and its $3z^2 - r^2$ band surprisingly becomes 3D due to the Ni-La hybridization, and the La-5d xy orbital also forms a 2D metallic band. Therefore, $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ is a dimensionality-controlled insulator-metal crossover system. © 2014 Author(s). All article content, except where otherwise noted, is licensed under a Creative Commons Attribution 3.0 Unported License. [<http://dx.doi.org/10.1063/1.4873537>]

I. INTRODUCTION

Insulator-metal transition (IMT) is an interesting property of transition metal oxides. It is scientifically important for the physics behind it, and it may also be explored for technological applications.¹ IMT is often driven by a competition between electron correlations and band effects. Moreover, very often the charge, spin, orbital, and lattice degrees of freedom get involved, making IMT to be a complex issue.² As well known, dimensionality (D) is another important factor to tune materials properties, and dimensionality controlled IMT has often been observed in films and superlattices.³⁻⁷ LaNiO_3 -based superlattice undergoes a metal-insulator transition when the thickness of LaNiO_3 is reduced to only a few unit cells.⁷ Moreover, the dimensionality-induced IMT occurs in bulk Ruddlesden-Popper series $\text{Sr}_{n+1}\text{Ir}_n\text{O}_{3n+1}$ ($n = 1, 2, \text{ and } \infty$).⁸ The bulk T'-type nickelates $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ ($n = 2, 3, \text{ and } \infty$)⁹⁻²¹ with infinite NiO_2 square planes seem to be another candidate for the dimensionality-controlled IMT. They contain bilayer, trilayer and infinite-layer of NiO_2 planes for $\text{La}_3\text{Ni}_2\text{O}_6$ ($n = 2$), $\text{La}_4\text{Ni}_3\text{O}_8$ ($n = 3$) and LaNiO_2 ($n = \infty$), respectively, as shown in Fig. 1. Owing to the sandwiching LaO fluorite blocks, the inter-bilayer (inter-trilayer) coupling is very weak and therefore $\text{La}_3\text{Ni}_2\text{O}_6$ ($\text{La}_4\text{Ni}_3\text{O}_8$) shows 2D features. In contrast, LaNiO_2 is expected to be 3D. Thus, the dimensionality of the electron system is changed from 2D to 3D as the number of NiO_2 planes (n) increases. Moreover, transport and magnetic measurements have shown that $\text{La}_3\text{Ni}_2\text{O}_6$ is a highly paramagnetic insulator¹⁰ with antiferromagnetic (AFM) spin fluctuations below 5 K²¹ and $\text{La}_4\text{Ni}_3\text{O}_8$ is an AFM insulator below 105 K,¹³ whereas LaNiO_2 exhibits a correlated metallic

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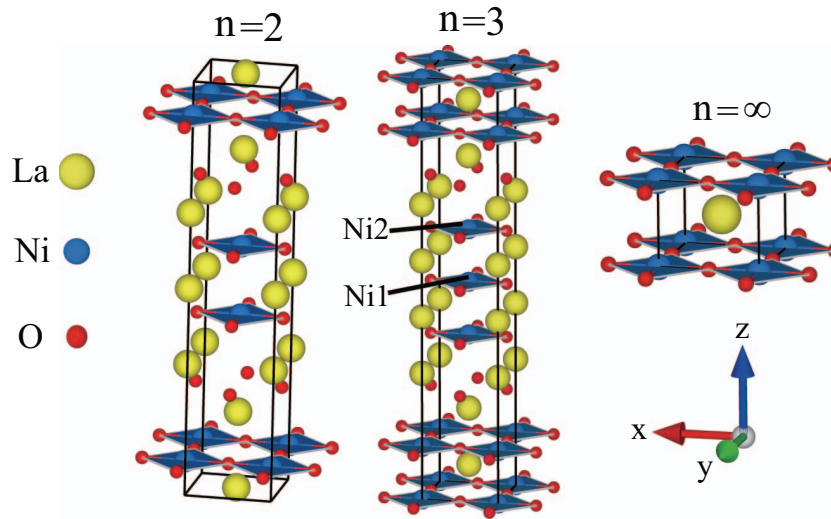


FIG. 1. The crystal structure of $n = 2$ ($\text{La}_3\text{Ni}_2\text{O}_6$), 3 ($\text{La}_4\text{Ni}_3\text{O}_8$) and ∞ (LaNiO_2) members. The corner-sharing NiO_2 square planes are highlighted in blue with Ni atoms at the centers. La atoms are represented by yellow (big) spheres and O atoms by red (small) spheres. For $n = 2$ member, interlayer $d_{\text{Ni-Ni}} = 3.19 \text{ \AA}$, intralayer $d_{\text{Ni-O}} = 1.9844 \text{ \AA}$; for $n = 3$ member, interlayer $d_{\text{Ni1-Ni2}} = 3.25 \text{ \AA}$, intralayer $d_{\text{Ni1-O}} = 1.9817 \text{ \AA}$, $d_{\text{Ni2-O}} = 1.9819 \text{ \AA}$; for $n = \infty$ member, interlayer $d_{\text{Ni-Ni}} = 3.375 \text{ \AA}$, intralayer $d_{\text{Ni-O}} = 1.9795 \text{ \AA}$.

behavior with short-ranged AFM ordering.¹⁶ So $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$, with $n = 2, 3$, and ∞ , have an insulator-metal crossover. However, a theoretical understanding of those diverse properties is far from being satisfactory. Poltavets *et al.*^{10,13} and Sarkar *et al.*¹² obtained a correlated metallic ground state for both $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$ from first-principles calculations. In contrast, Pardo and Pickett^{11,15} and Liu *et al.*¹⁹ found a molecular correlated insulating ground state, which is similar to a partially charge-disproportionated insulating state proposed by Wu.²⁰ Anisimov *et al.*¹⁸ reported that LaNiO_2 is an AFM insulator similar to CaCuO_2 (Ref. 22), but it was suggested to be nonmagnetic (NM) and probably metal by Lee and Pickett.¹⁷ Apparently, those ground-state solutions are contradictory. We are therefore motivated to carry out a systematic study on $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ and to probe a possible impact of the dimensionality on their electronic structures.

In this paper, we have performed electron-correlation corrected density-functional calculations for $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ ($n = 2, 3$, and ∞). The insulator-metal crossover in $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ is found to be induced by dimensionality. When the dimensionality (or n) increases, the active $3z^2 - r^2$ orbital state is gradually developed from the discrete molecular levels for 2D $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$ to continuous solid band for 3D LaNiO_2 . Meanwhile, the filling of down-spin $3z^2 - r^2$ orbital varies. Thus, a molecular insulating state is formed in 2D $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$, while a metallic state is found for 3D LaNiO_2 . Our results also indicate that the metallic state of LaNiO_2 is induced by the Ni- $3d$ /La- $5d$ hybridization, which gives rise to the unusual 3D Ni- $3d$ $3z^2 - r^2$ metallic band and the 2D La- $5d$ xy metallic band.

II. COMPUTATIONAL DETAILS

Our calculations were performed using the standard full-potential linearized augmented plane wave code WIEN2k²³ within density functional theory. We have first done structural optimization and find that the equilibrium volumes are slightly different from the experimental ones by 0.6%, 0.75% and -0.3% at most, and that the Ni-Ni and Ni-O distances of the most concern change by 0.2%, 0.24% and -0.1% at most for $\text{La}_3\text{Ni}_2\text{O}_6$, $\text{La}_4\text{Ni}_3\text{O}_8$ and LaNiO_2 , respectively. Therefore, the experimental lattice parameters (see Table I) are well reproduced by our calculations. We present below the calculated results using those experimental structure parameters. The muffin-tin sphere radii were chosen to be 2.35, 1.97 and 1.75 bohr for La, Ni and O atoms, respectively. The cutoff

TABLE I. The lattice constants a , c (Å) and atomic coordinates for $\text{La}_3\text{Ni}_2\text{O}_6$ (Space group: $I4/mmm$, Ref. 9), $\text{La}_4\text{Ni}_3\text{O}_8$ (Space group: $I4/mmm$, Ref. 13) and LaNiO_2 (Space group: $P4/mmm$, Ref. 16), respectively.

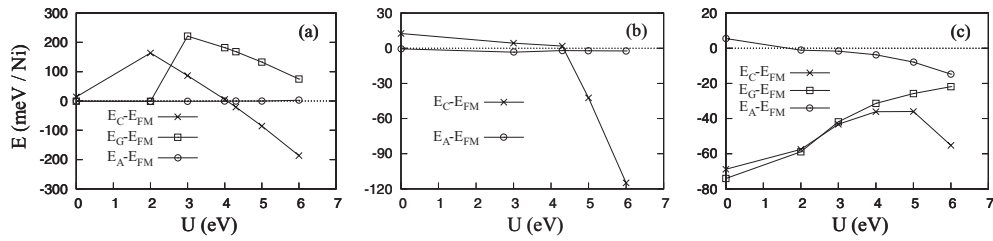
	$\text{La}_3\text{Ni}_2\text{O}_6$	$\text{La}_4\text{Ni}_3\text{O}_8$	LaNiO_2
a	3.9686	3.9633	3.9592
c	19.3154	26.0373	3.3745
La1	(0,0,0.5)	(0,0,0.4333)	(0.5,0.5,0.5)
La2	(0,0,0.3170)	(0,0,0.2996)	
Ni1	(0,0,0.0826)	(0,0,0)	(0,0,0)
Ni2		(0,0,0.1248)	
O1	(0,0.5,0.25)	(0,0.5,0)	(0.5,0,0)
O2	(0,0.5,0.0838)	(0,0.5,0.25)	
O3		(0,0.5,0.1261)	

parameter $R_{mt}K_{max}$ was set to 7.0 (the smallest muffin-tin radius multiplied by the maximal K vector which truncates the plane-wave expansion in the basis set) and G_{max} was set to 12 for the charge density Fourier expansion. Here, 500 and 1000 k -points were used over the first Brillouin zone for $\text{La}_3\text{Ni}_2\text{O}_6$ and LaNiO_2 , respectively. Self-consistency was considered to be achieved when the total energy difference between succeeding iterations is less than 10^{-5} Ry/unit cell. The generalized gradient approximation (GGA) by Perdew, Burk, and Ernzerhof²⁴ was employed for the exchange-correlation potential. To properly describe the strong electron correlation associated with the Ni $3d$ states, the GGA+ U scheme in the so-called fully localized limit²⁵ was used, where $U_{eff} = U - J$ (U and J are on-site Coulomb and exchange interaction, respectively) was used instead of U .²⁶ The parameters U_{eff} have been investigated by examining the evolution of the total energy of different spin configurations with variation of U_{eff} . To clarify the magnetic structure, $\sqrt{2} \times \sqrt{2} \times 1$ and $\sqrt{2} \times \sqrt{2} \times 2$ supercell calculations were performed for $\text{La}_3\text{Ni}_2\text{O}_6$ and LaNiO_2 , respectively, with four possible spin configurations: C-AFM (AFM within layers, FM between layers), A-AFM (FM within layers, AFM between layers), G-AFM (AFM within layers and AFM between layers) and FM spin configurations.

III. RESULTS AND DISCUSSIONS

In $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ compounds, the electron correlation values may be one of causes that the calculated ground state remains controversial.^{19,27} Therefore, it is necessary to investigate the proper electron correlation values of Ni $3d$ for $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$. To choose the reasonable electron correlation values, we examine the evolution of the total energy of different spin configurations with variation of U . The ground state of $\text{La}_3\text{Ni}_2\text{O}_6$ is a function of U , as shown in Fig. 2(a). $\text{La}_3\text{Ni}_2\text{O}_6$ exhibits the metallic ground state by using small electron correlation value ($U = 0-4$ eV), which is inconsistent with the experimental data.^{10,21} The experimentally observed insulating ground state of $\text{La}_3\text{Ni}_2\text{O}_6$ is obtained when $U = 4.3-6$ eV. For $\text{La}_4\text{Ni}_3\text{O}_8$, the metallic state is most stable if $0 \leq U \leq 4.3$ eV, whereas the insulating state is the ground state when $5 \leq U \leq 6$ eV¹⁹ (see Fig. 2(b)). Thus, $U = 5-6$ eV¹⁹ is the proper Ni $3d$ electron correlation values for $\text{La}_4\text{Ni}_3\text{O}_8$. Moreover, LaNiO_2 exhibits observed correlated metallic behavior¹⁶ and no significant change to electronic structure, as changing U from 3 to 6 eV (see Fig. 2(c)). Hence, the $U = 5$ eV is the appropriate Ni $3d$ electron correlation value in $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ compounds.

The relative energies of various spin configurations are studied within GGA+ U ($U = 5$ eV). For $\text{La}_3\text{Ni}_2\text{O}_6$, as shown in Table II, both FM and A-AFM states exhibit a metallic feature which disagrees with the experimental data. Both C-AFM and G-AFM states exhibit experimentally observed insulating behavior, but the C-AFM state is more stable than the G-AFM state in energy by 218 meV/Ni. Therefore, the C-AFM state is the ground state which is consistent with the results reported by Pardo and Pickett.¹¹ No long-ranged magnetic ordering was found¹⁰ in $\text{La}_3\text{Ni}_2\text{O}_6$, but the nuclear magnetic resonance (NMR) data revealed the presence of AFM spin fluctuations at low temperature.²¹ It suggests a short-ranged AFM ordering. For $\text{La}_4\text{Ni}_3\text{O}_8$, the energy of C-AFM state

FIG. 2. Relative total energy of different magnetic states as a function of U for (a) $\text{La}_3\text{Ni}_2\text{O}_6$, (b) $\text{La}_4\text{Ni}_3\text{O}_8$ and (c) LaNiO_2 .TABLE II. The total energy ΔE (meV/Ni) relative to the lowest-energy state, the magnetic moment M_s (μ_B) of Ni, band gap E_g (eV) for different magnetic configurations within GGA+ U ($U_{\text{eff}} = 5$ eV). In the calculations, the magnetic moments are assumed to be along the crystallographic c -axis. Actually they are rotationally free in the space without the spin-orbit coupling effect. “–” denotes metal. The data of $\text{La}_4\text{Ni}_3\text{O}_8$ are from Ref. 19

		FM	A-AFM	C-AFM	G-AFM
$\text{La}_3\text{Ni}_2\text{O}_6$	ΔE	86	85	0	218
	M_s	0.69/0.60	± 0.6	± 1.43	0.92/-1.54
	E_g	–	–	1.0	1.4
$\text{La}_4\text{Ni}_3\text{O}_8$	ΔE	42.32	40.16	0	
	M_s	0.79/0.77	± 0.8	1.44/1.29	
	E_g	–	–	0.7	
LaNiO_2	ΔE	36	28	0	10
	M_s	1	± 1.08	± 1.13	± 1.06
	E_g	–	–	–	–

is lower than that of FM and A-AFM states by about 80 meV/Ni¹⁹ (see Table II), and consequently the C-AFM state is the ground state. And similarly, the C-AFM state is most stable for LaNiO_2 , which is lower in energy than FM, A-AFM and G-AFM states by 36, 28 and 10 meV/Ni, respectively. Neutron diffraction and spin susceptibility measurements indicated that LaNiO_2 shows short-ranged AFM ordering.¹⁶ Lee and Pickett¹⁷ have suggested that LaNiO_2 may be a NM metal. However, our obtained NM state is less stable than the C-AFM state by 70 meV/Ni. Consequently, the C-AFM state is preferred for $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ compounds, although AFM ordering is a marginal occurrence and only short-ranged AFM ordering²⁸ exists in $\text{La}_3\text{Ni}_2\text{O}_6$ and LaNiO_2 .

$\text{La}_3\text{Ni}_2\text{O}_6$ ($n = 2$) exhibits insulating character with a band gap of 1 eV (see Fig. 3(a)). The states driven by Ni $3d$ -O $2p$ hybridized orbitals mainly distribute from -6 to -0.2 eV and from 3 to 5 eV, and the states near the Fermi level are mainly driven by Ni $3d$ orbitals. According to a simple electron count, the Ni ions have 1.5+ oxidation state with charge $d^{8.5}$. From Fig. 3(a), we can see that the Ni ions hold the high-spin state ($S = 3/4$, $M_s = 1.5 \mu_B$), which is consistent with the previous solution by Pardo and Pickett.¹¹ The t_{2g} orbitals of Ni- $3d$ are completely occupied, distributing from -5.6 eV to -0.7 eV (not shown here). The up-spin $x^2 - y^2$ orbital is fully occupied, while the down-spin $x^2 - y^2$ orbital is empty, showing the large exchange splitting (due to the electron correlation rather than Hund exchange). The up-spin $3z^2 - r^2$ orbital is fully filled, distributing from -6 eV to -3 eV. The down-spin $3z^2 - r^2$ orbital is half filled, contributing $0.5 \mu_B$ to Ni spin moment. Particularly, its filled and unfilled bands correspond to highly localized molecular levels.

$\text{La}_4\text{Ni}_3\text{O}_8$ ($n = 3$) also shows insulating character with a band gap of 0.7 eV¹⁹ (see Fig. 3(b)). It has a similar density of states (DOS) except that down-spin $3z^2 - r^2$ orbital is two-thirds filled, as shown in Fig. 3(b). Its unfilled band is separated from filled bands by band gap of 0.7 eV and all of them are quite localized as in $\text{La}_3\text{Ni}_2\text{O}_6$. The oxidation state of the Ni ions is 1.33+ with charge $d^{8.67}$ and the Ni ions are in high-spin state ($S = 2/3$, $M_s = 1.33 \mu_B$).^{15, 19} The unfilled down-spin $x^2 - y^2$ orbital contributes $1 \mu_B$ to Ni spin moment and the two-thirds filled down-spin $3z^2 - r^2$ orbital contributes $0.33 \mu_B$.¹⁵

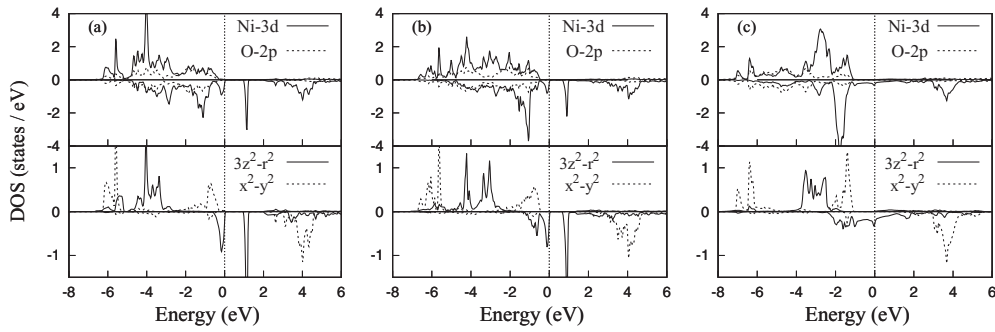


FIG. 3. The Ni-3d orbital-resolved partial density of states (DOS) and O-2p DOS obtained from GGA+ U ($U = 5$ eV) in C-AFM ground state for (a) $\text{La}_3\text{Ni}_2\text{O}_6$, (b) $\text{La}_4\text{Ni}_3\text{O}_8$, and (c) LaNiO_2 .

LaNiO_2 ($n = \infty$) exhibits a metallic character. The DOS crossing the Fermi level has a large contribution from $3z^2 - r^2$ orbital and a small contribution from O-2p orbitals, as shown in Fig. 3(c). LaNiO_2 has $\text{Ni}^+ : d^9$ cations, the spin moment is increased to $1.13 \mu_B$ because of the hybridization between the $3z^2 - r^2$ and other empty orbitals. Like $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$, the t_{2g} orbitals of Ni-3d are completely occupied, distributing from -6.1 eV to -1.3 eV. The up-spin $x^2 - y^2$ orbital is filled, while the down-spin $x^2 - y^2$ orbital is unfilled, respectively lying 1.1 eV below and 3 eV above the Fermi level. In contrast to $\text{La}_3\text{Ni}_2\text{O}_6$ and $\text{La}_4\text{Ni}_3\text{O}_8$, the down-spin $3z^2 - r^2$ orbital now forms a broad metallic band crossing the Fermi level due to the Ni-La hybridization (see below). The Ni-3d and La-5d hybridized orbitals were also found in Ref. 17.

Next, we seek the origin of insulator-metal crossover upon increasing the n from $n = 2$ ($\text{La}_3\text{Ni}_2\text{O}_6$) and $n = 3$ ($\text{La}_4\text{Ni}_3\text{O}_8$) to $n = \infty$ (LaNiO_2) using the above results. The t_{2g} and $x^2 - y^2$ orbitals of Ni-3d in these compounds are away from the Fermi level and do not contribute to the conductivity. In addition, as its exchange splitting is large, the top of the up-spin $3z^2 - r^2$ band is lower than the bottom of down-spin $3z^2 - r^2$ band (see Fig. 3). Therefore, the state determining their conductivity is the partially filled down-spin $3z^2 - r^2$ orbital which is active in the vicinity of the Fermi level. The down-spin $3z^2 - r^2$ orbital evolves from molecular level states to a solid band state and its filling varies from $1/2$ to $2/3$ and then to 1 , when n or the dimensionality increases.

When $n = 2$, $\text{La}_3\text{Ni}_2\text{O}_6$ has NiO_2 bilayers separated by LaO fluorite blocks, thereby showing 2D features see Fig. 1. This strong structural confinement makes the NiO_2 bilayer of $\text{La}_3\text{Ni}_2\text{O}_6$ form a molecular dimer via the down-spin $3z^2 - r^2$ orbital along the z -axis. The down-spin $3z^2 - r^2$ orbital within dimer is split into discrete bonding (b) and antibonding (ab) levels (see Fig. 4(a)). These molecular levels are highly localized with their level-width being less than 0.65 eV (see Fig. 3(a)) as a consequence of the limited-dimensionality. This molecular picture can be understood by a simple two-site tight-binding (TB) model. According to the TB model, the energy separation between bonding and antibonding levels is $2t_2$ within dimer (t_2 is the interlayer hopping in $\text{La}_3\text{Ni}_2\text{O}_6$). From Fig. 3(a), we can see that the bonding and antibonding levels of $\text{La}_3\text{Ni}_2\text{O}_6$ are located at -0.2 and 1.1 eV, respectively. Then, we can estimate the hoppings t_2 to be 0.65 eV. It is the bonding-antibonding splitting which determines the insulating gap, see Figs. 3(a) and 4(a).

When $n = 3$, $\text{La}_4\text{Ni}_3\text{O}_8$ has NiO_2 trilayers separated by LaO fluorite blocks, thereby showing also 2D features. This structural confinement makes NiO_2 trilayer of $\text{La}_4\text{Ni}_3\text{O}_8$ form a molecular trimer via the interlayer interaction mediated by the down-spin $3z^2 - r^2$ orbital.¹⁵ According to the three-site TB model, the down-spin $3z^2 - r^2$ orbital within dimer is split into discrete bonding (b), nonbonding (nb), antibonding (ab) levels and the bonding-antibonding splitting value is $2\sqrt{2}t_3$ (t_3 is the hopping in $\text{La}_4\text{Ni}_3\text{O}_8$) (see Fig. 4(b)). The bonding, nonbonding and antibonding levels of $\text{La}_4\text{Ni}_3\text{O}_8$ are located at -1 , -0.1 and 0.8 eV (see Fig. 3(b)), respectively, thus the hoppings t_3 is estimated to be 0.64 eV. t_3 is slightly smaller than t_2 , which originates from the tiny difference in structural details (The Ni-Ni interlayer distance is 3.19 Å for $\text{La}_3\text{Ni}_2\text{O}_6$ and 3.25 Å for $\text{La}_4\text{Ni}_3\text{O}_8$). These molecular levels are also quite localized with their level-width being less than 0.75 eV (see Fig. 3(b)). Compared with $\text{La}_3\text{Ni}_2\text{O}_6$, the bonding-antibonding splitting is enhanced and the third

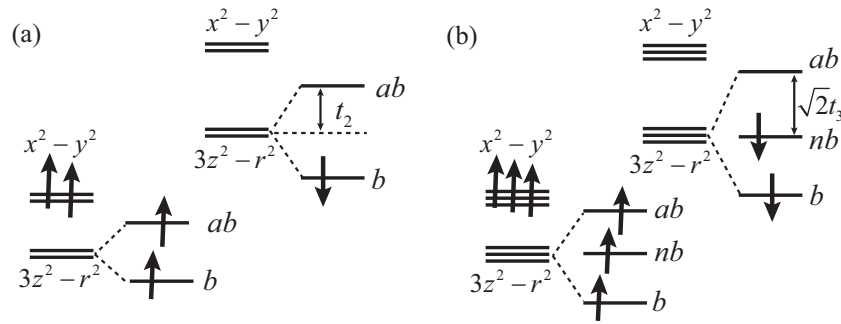


FIG. 4. The molecular level diagram for (a) $\text{La}_3\text{Ni}_2\text{O}_6$ and (b) $\text{La}_4\text{Ni}_3\text{O}_8$. Only the e_g states are depicted, with the bonding (b), antibonding (ab), and nonbonding (nb) levels. t_2 (the interlayer hopping in $\text{La}_3\text{Ni}_2\text{O}_6$) and t_3 (the interlayer hopping in $\text{La}_4\text{Ni}_3\text{O}_8$) are about 0.65 eV and 0.64 eV, respectively.

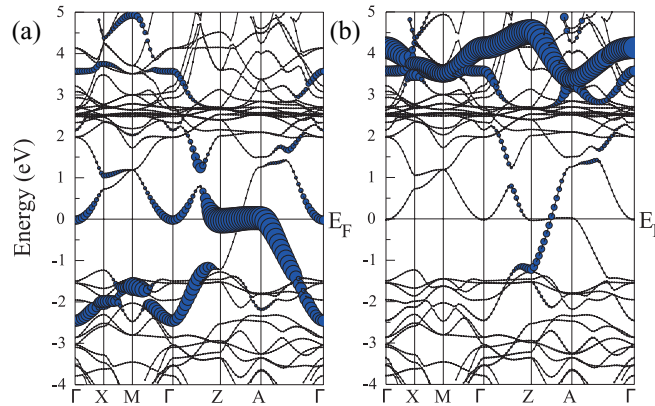


FIG. 5. The minority-spin band structure of LaNiO_2 with the highlighted Ni-3d $3z^2 - r^2$ orbital in (a) and La-5d xy orbital in (b). In (b) the metallic band along Z-A direction is mainly due to the La-5d xy state.

molecular level is inserted, due to the additional NiO_2 layer in $\text{La}_4\text{Ni}_3\text{O}_8$. Thus, a smaller band gap is formed between the filled nonbonding level and the unfilled antibonding one for 2/3-filled down-spin $3z^2 - r^2$ orbital.

When $n = \infty$, LaNiO_2 shows 3D features due to the absent of LaO confining block, therefore the $3z^2 - r^2$ orbital expands to the continuous band. On the one hand, LaNiO_2 with Ni^{2+} (d^8) may be expected to have a completely occupied down-spin $3z^2 - r^2$ orbital, and thus to have an insulating behavior. However, the down-spin $3z^2 - r^2$ orbital actually forms a broad metallic band and the La-5d bands also cross Fermi level, as shown in Fig. 5. On the other hand, the bandwidth of down-spin $3z^2 - r^2$ orbital would be $4t$ if it is the normal 1D type along the z -axis, according to the TB model. As the Ni-Ni interlayer distance of 3.375 Å in LaNiO_2 is larger than that in $\text{La}_4\text{Ni}_3\text{O}_8$ (3.25 Å), the hopping parameter t in the former would be smaller than t_3 in the latter. That is to say, the bandwidth of down-spin $3z^2 - r^2$ orbital in LaNiO_2 would be smaller than $4t_3$ if the $3z^2 - r^2$ is 1D as usual. However, the actual down-spin $3z^2 - r^2$ bandwidth of more than 4 eV in LaNiO_2 (see Figs. 3(c) and 5(a)) is much larger than $4t_3$ (about 2.6 eV). This suggests that besides the interlayer Ni-Ni hopping, the Ni-La hybridization greatly enhances the $3z^2 - r^2$ bandwidth and results in a metallic state. The higher on-site energy of Ni^{2+} 3d orbital, compared with $\text{Ni}^{1.5+}$ and $\text{Ni}^{1.33+}$, reduces the energy separation between Ni-3d and diffusive La-5d bands, thereby enhancing the hybridization between them.¹⁷ Thus, a finite electron transfer from Ni-3d $3z^2 - r^2$ to La-5d xy results in a metallic state. Owing to the Ni 3d-La5d hybridization, the $3z^2 - r^2$ band has a large dispersion along A- Γ direction (see Fig. 5(a)), showing a remarkable 3D character but not the normal 1D. Moreover, La xy forms a 2D metallic band along the Z-A direction, see Fig. 5(b).

IV. CONCLUSIONS

In summary, we have investigated the electronic structure of low-valence layered nickelates $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ using first-principle calculations. We find that $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$ is a dimensionality-controlled insulator-metal crossover system. When the dimensionality (or n) increases, the active $3z^2 - r^2$ orbital state evolves from molecular levels to a solid band and its corresponding filling is increased. The $3z^2 - r^2$ orbital split into bonding and antibonding levels for 2D $\text{La}_3\text{Ni}_2\text{O}_6$ and its corresponding 1/2-filling lead to a molecular insulating state with large band gap. For 2D $\text{La}_4\text{Ni}_3\text{O}_8$, the $3z^2 - r^2$ orbital split into bonding, nonbonding and antibonding levels and its corresponding 2/3-filling lead to a molecular insulating state with relatively small band gap. For 3D LaNiO_2 , however, the $3z^2 - r^2$ orbital is expanded into a continuous metallic band. Owing to the Ni-3*d* and La-5*d* hybridization and a finite charge transfer, the $3z^2 - r^2$ orbital shows a surprising 3D behavior, and La-5*d* *xy* orbital forms a 2D metallic band. The present study clarifies the important role of the dimensionality and the inter-orbital hybridization in determining the electronic structure of insulator-metal crossover system $\text{La}_{n+1}\text{Ni}_n\text{O}_{2n+2}$.

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